

**ABDULLAH GÜL UNIVERSITY  
GRADUATE SCHOOL OF ENGINEERING & SCIENCE  
ELECTRICAL AND COMPUTER ENGINEERING PROGRAM  
COURSE DESCRIPTION AND SYLLABUS**

Course Title	Code	Semester	T+L Hours	Credit	ECTS
SEMICONDUCTOR PROCESS AND DEVICE FABRICATION	ECE-686	FALL-SPRING	3 + 0	3	7,5

**Prerequisite Courses** None

<b>Type</b>	Selective
<b>Language</b>	English
<b>Coordinator</b>	Assist. Prof. Dooyoung Hah
<b>Instructor</b>	Assist. Prof. Dooyoung Hah
<b>Adjunt</b>	none
<b>Aim</b>	Detailed coverage of microfabrication process technologies for various devices including CMOS and MEMS devices, and modeling of individual processes. Gaining design experience of unit processes and process integration.
<b>Learning Outcomes</b>	To provide an opportunity for students to <ul style="list-style-type: none"> <li>• learn the scientific principles and technological development in lithography process</li> <li>• learn the scientific principles, technological development, and theoretical modeling of thermal oxidation process</li> <li>• learn the scientific principles, technological development, and theoretical modeling of impurity doping processes</li> <li>• learn the scientific principles, technological development, and theoretical modeling of thin film deposition processes</li> <li>• learn the scientific principles and technological development in etching processes</li> <li>• learn the scientific principles and technological development in micromachining processes</li> <li>• learn the methodology of process integration design</li> </ul>
<b>Course Content</b>	<ul style="list-style-type: none"> <li>• Review of semiconductor materials,</li> <li>• CMOS fabrication process flow,</li> <li>• Review of semiconductor crystal structures and wafer growth,</li> <li>• Photolithography processes,</li> <li>• Thermal oxidation processes of silicon,</li> <li>• Diffusion processes and ion implantation processes,</li> <li>• Thin film deposition processes,</li> <li>• Wet and dry etching processes,</li> <li>• Bulk micromachining and surface micromachining processes</li> </ul>

**WEEKLY TOPICS AND PRELIMINARY STUDY**

Week	Topic	Preliminary Study
1	Introduction to microfabrication: Historical background, cleanroom, integrated circuits, technology development trend, review of semiconductor materials	The relevant articles from the literature
2	CMOS fabrication process flow: CMOS process flow details from wafer preparation to back-end processes, design of process integration	The relevant articles from the literature
3	Semiconductor crystal structures and wafer growth: Crystal structure, diamond lattice, Czochralski growth, float-zone method, electrical and physical measurements of wafer characteristics	The relevant articles from the literature
4	Photolithography processes: Exposure systems, light sources, effects of lightwave properties to photolithography processes, properties of photoresists	The relevant articles from the literature
5	Photolithography processes: Advanced photolithography, optical proximity correction, phase shift masks, immersion lithography, double patterning, x-ray lithography, e-beam lithography	The relevant articles from the literature
6	Thermal oxidation of silicon: Basic properties of silicon dioxide, modeling of thermal oxidation, doping effects, measurement methods, high k dielectric materials	The relevant articles from the literature
7	Dopant diffusion: Atomic diffusion mechanisms, diffusion model, two-step diffusion processes, extrinsic diffusion, design of diffused resistors	The relevant articles from the literature
8	Midterm exam	The relevant articles from the literature
9	Ion implantation: Ion implanter, stopping mechanisms, impurity profile, asymmetry in profiles, implantation masking, implantation damage, channeling effects	The relevant articles from the literature

10	Thin film deposition: Material consideration, chemical vaport deposition (CVD) processes, atmospheric pressure CVD, low pressure CVD, plasma-enhanced CVD	The relevant articles from the literature
11	Thin film deposition: Physical vapor deposition processes, thermal evaporation, e-beam evaporation, DC sputtering, RF sputtering, metal interconnect formation	The relevant articles from the literature
12	Etching processes: Selectivity and anisotrophy, etch process control, wet etching	The relevant articles from the literature
13	Etching processes: Plasma etching mechanisms – chemical and physical, ion-enhanced etching, loading effect	The relevant articles from the literature
14	Student presentation: study of advanced topics in semiconductor fabrication processes and presentations by students	The relevant articles from the literature
15	Micromachining: bulk micromachining, crystal-orientation-dependent etching, etch stops, deep reactive ion etch, surface micromachining, stiction prevention, wafer bonding methods	The relevant articles from the literature
16	Final Exam	

### SOURCES

<b>Lecture Notes</b>	Lecture slides
<b>Other Sources</b>	<p><b>Course Textbook:</b> "Silicon VLSI Technology – Fundamentals, Practice and Modeling," J. Plummer, M. Deal, and P. Griffin, 2000, Prentice Hall.</p> <p><b>Additional Materials:</b></p>

### COURSE MATERIALS SHARING

<b>Documents</b>	Lecture notes and slides
<b>Homeworks</b>	Students will be given one homework in every two weeks
<b>Exams</b>	1 Midterm and 1 Final Exam

### EVALUATION SYSTEM

SEMESTER STUDY	NUMBER	CONTRIBUTION
Midterm	1	35
Homework	8	10
Semester project	1	20
<b>SUB-TOTAL</b>		65
<b>Contribution of Semester Study</b>		65
<b>Contribution of Final Exam</b>	1	35
<b>TOTAL</b>		100

### Course Category

Sciences and Mathematics	20%
Engineering	80%
Social Sciences	0%

### RELATIONSHIPS BETWEEN LEARNING OUTCOMES AND PROGRAM QUALIFICATIONS

	No Program Qualifications	Contribution Level				
		1	2	3	4	5
1	The skills of using mathematics, science and engineering information in advanced research					<b>X</b>
2	The skills of analyzing, designing and/or implementing an original system that will be able to solve an engineering problem					<b>X</b>
3	The skills of using the required software, hardware and modern measurement equipments in their field of research					<b>X</b>
4	The skills of planning independent research and implementing in detail					<b>X</b>
5	The skills of following literature, listening to and making technical presentation, writing a paper in academic level					<b>X</b>

